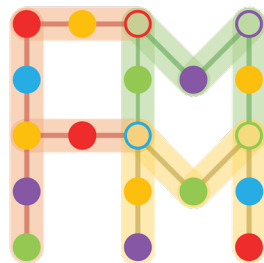




Enhanced photodetection with BP – organic hybrid

12th December 2022

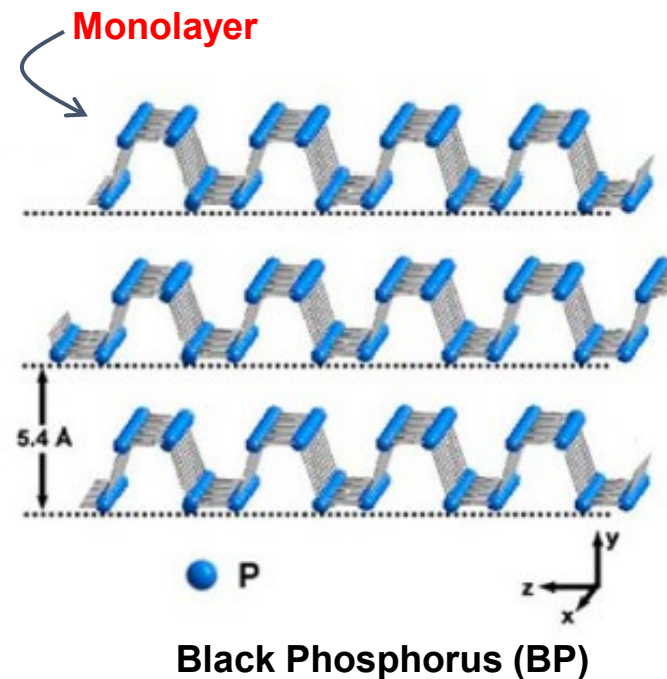
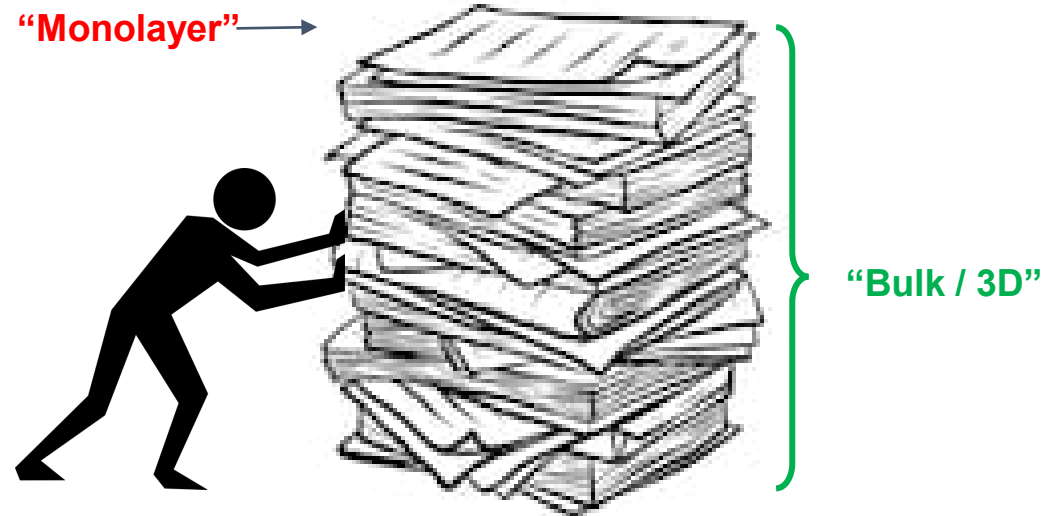
Jamie (Mei Xian) Low



Two-dimensional (2D) Materials



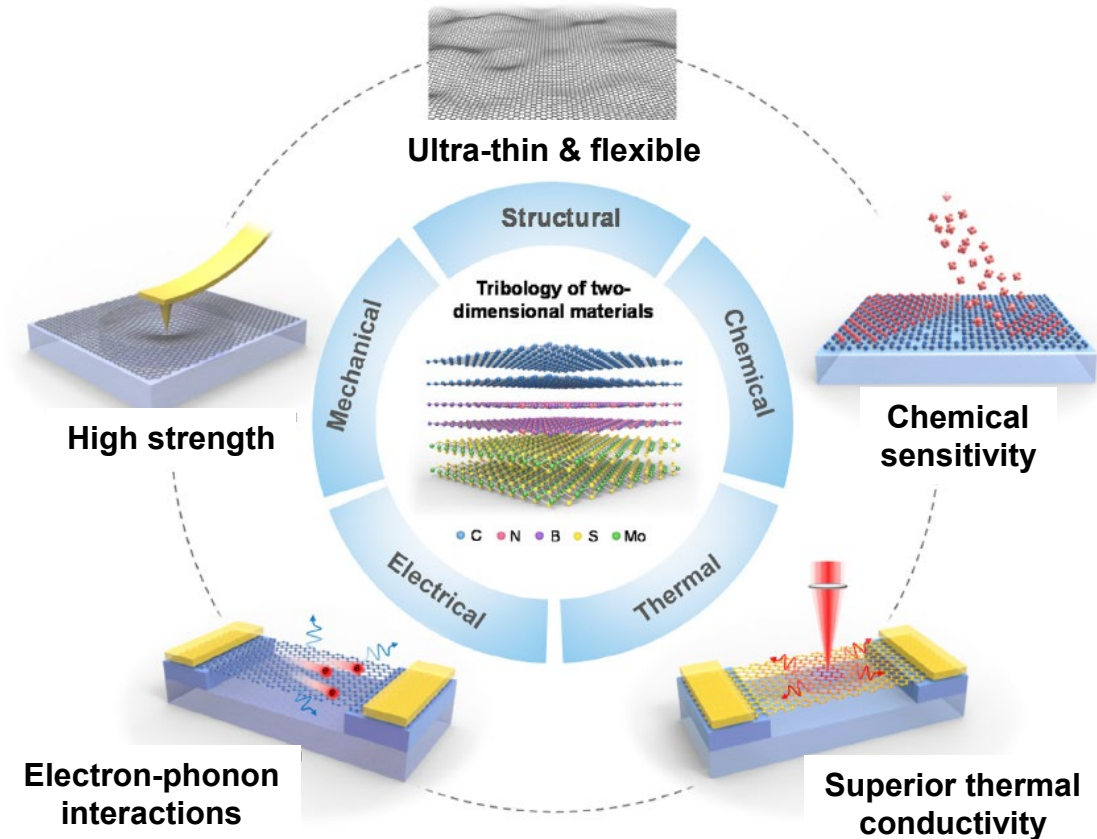
- Layered materials, weak interlayer (van der Waals) forces
- Single layer of atoms / molecules



Chem Rev 117, 6225 (2017)

Two-dimensional (2D) Materials

- Exceptional physical, chemical, electronic properties
- Increased carrier mobility due to quantum confinement
- Applications
 - Optoelectronics, gas sensors, piezoelectronics, biosensors etc



Materials Today **26**, 67 (2019)

Black phosphorus (BP)

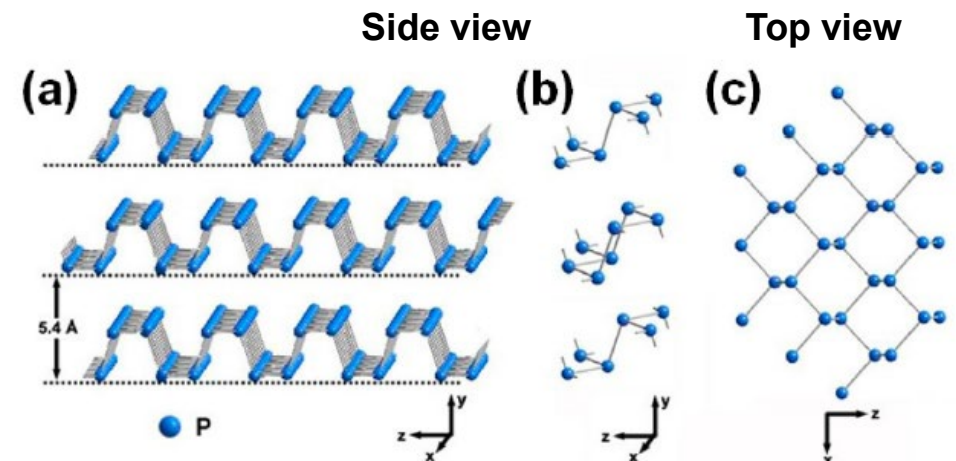


- Thickness dependent direct band-gap
 - 0.3 eV (bulk) → 2.0 eV (monolayer)
- High carrier mobility ($> 10^3 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$)
- In-plane anisotropy
 - Electrical and optical
- Applications:
 - Optoelectronics, Humidity sensors
- **Disadvantage → degrades at ambient conditions (passivation techniques available)**

Bulk BP



2D Semiconductors, 2020

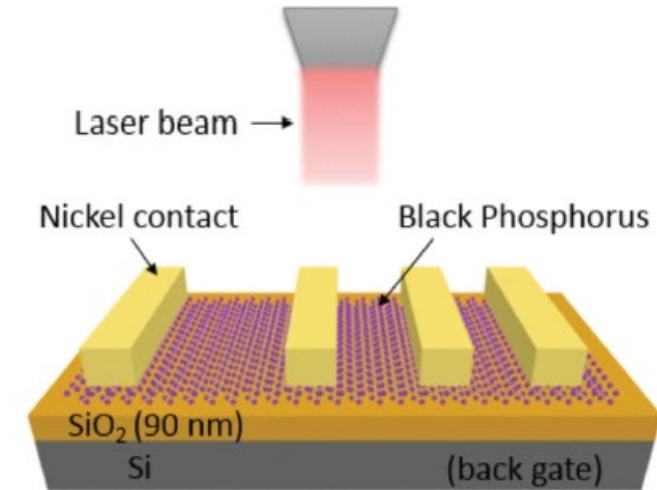


Chem Rev 117, 6225 (2017)

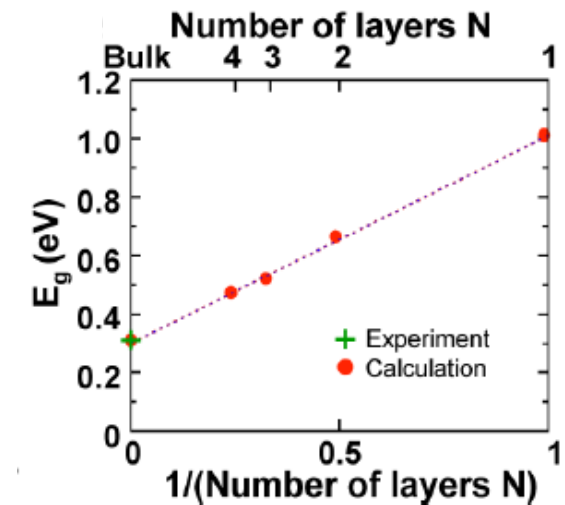
Multilayer BP Photodetectors



- UV – visible or mid-IR photo absorption
 - 280 nm – 600 nm (UV-Vis), $\sim 3 \mu\text{m}$ (mid-IR)
- Requires gating (external electric field) to achieve broadband photodetection $> 600 \text{ nm}$
 - High power consumption
 - Non-gated devices \rightarrow responsivity $\sim 2 - 5 \text{ mA W}^{-1}$ (visible: 532 nm – 640 nm)
- Thickness tuneable bandgap to manipulate optoelectronic properties
 - Difficulties in controlling thickness through mechanical and liquid exfoliation without introducing defects



Advanced Materials **28**, 3481 (2016)

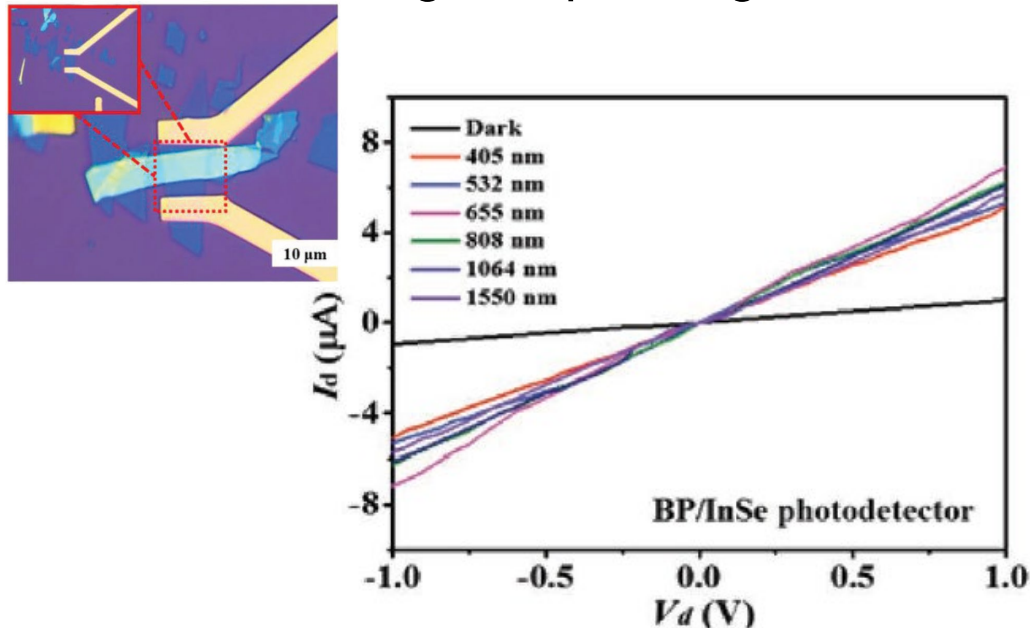


ACS Nano **8**, 4033 (2014)

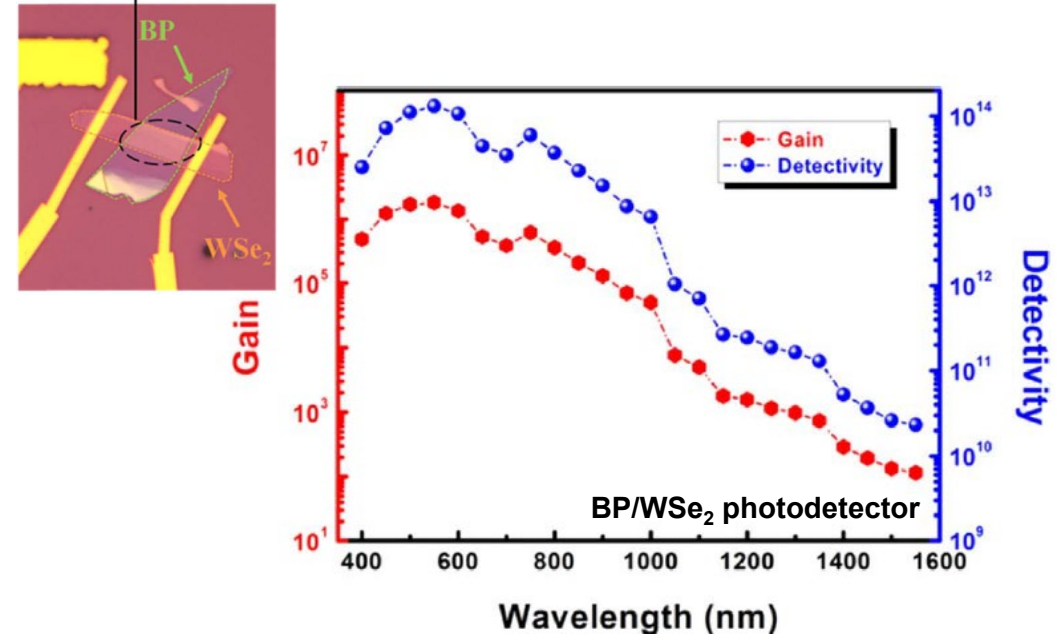
Tuning BP Characteristics (Hybridization)



- Achieving broadband (UV – IR) photodetection with hybridization
 - Heterostructuring with other 2D materials
 - Accurate positioning needed and not scalable
 - Requires higher operating bias to overcome barrier



Advanced Optical Materials 7, (2019)

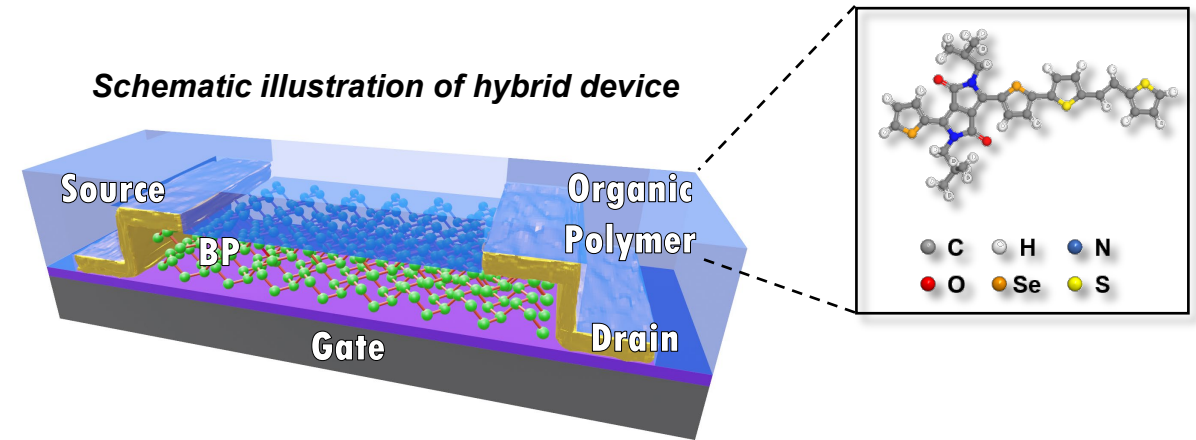


Nano Energy 37, (2017)

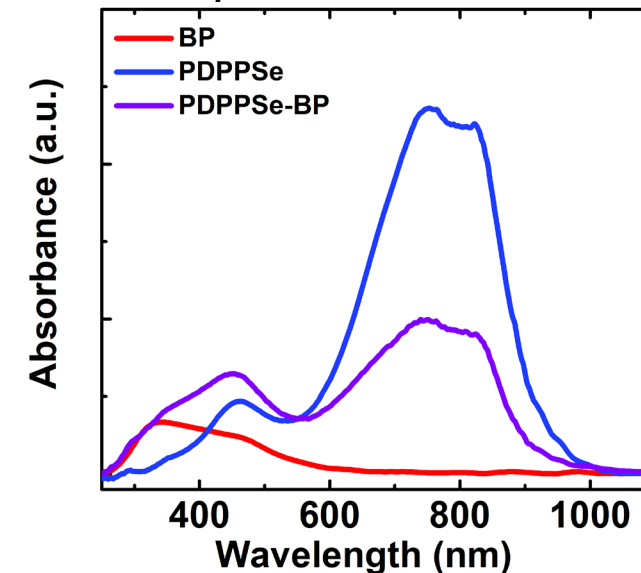
BP – Organic Hybrid



- DPP semiconducting polymer
 - High optical absorption in Visible-IR
 - Low band-gap
- Inorganic (BP) + organic (DPP) semiconductor hybrid
 - Simple scalable hybridization process
 - Combined optical absorbance of both materials
 - UV to near-IR



Optical absorbance curve

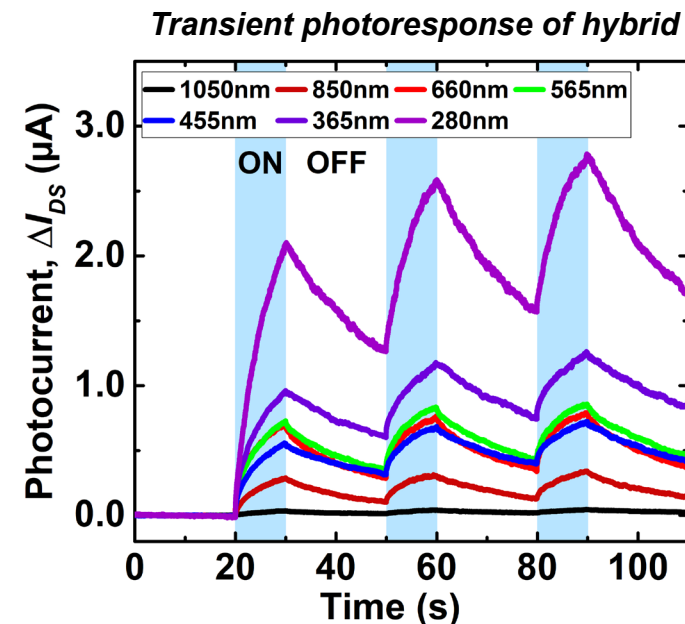
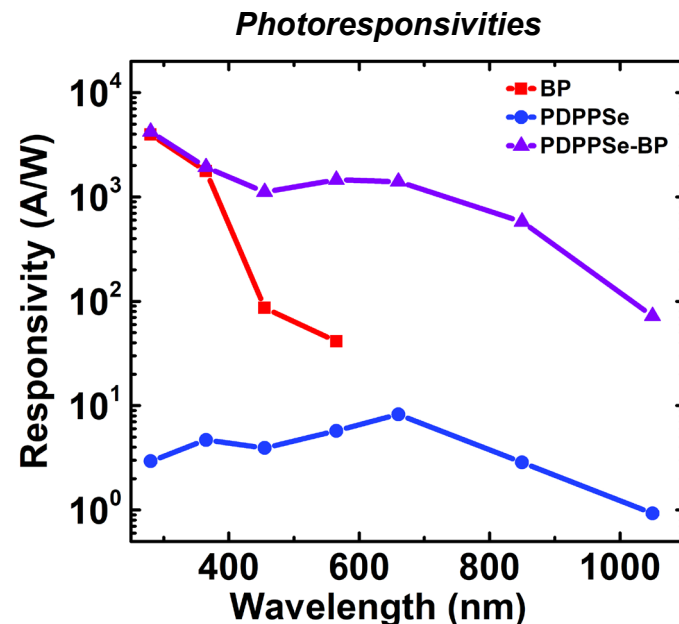


DPP: Diketopyrrolopyrole

BP – Organic Hybrid



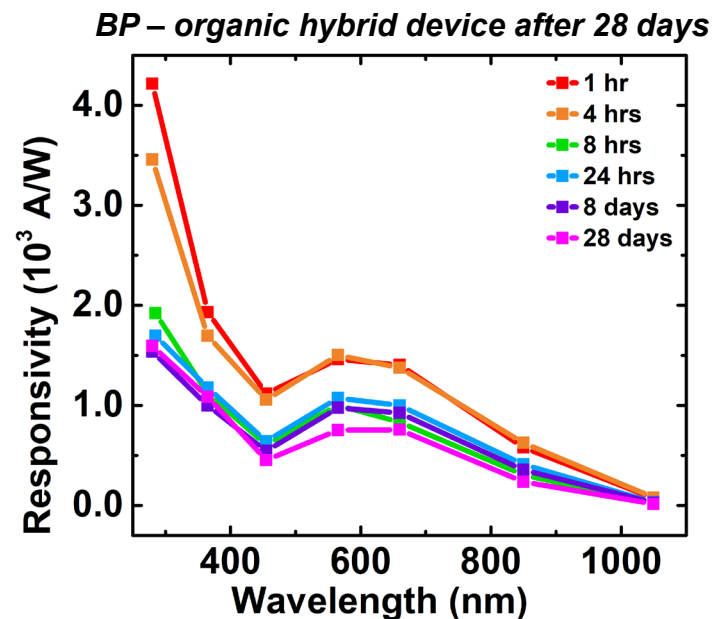
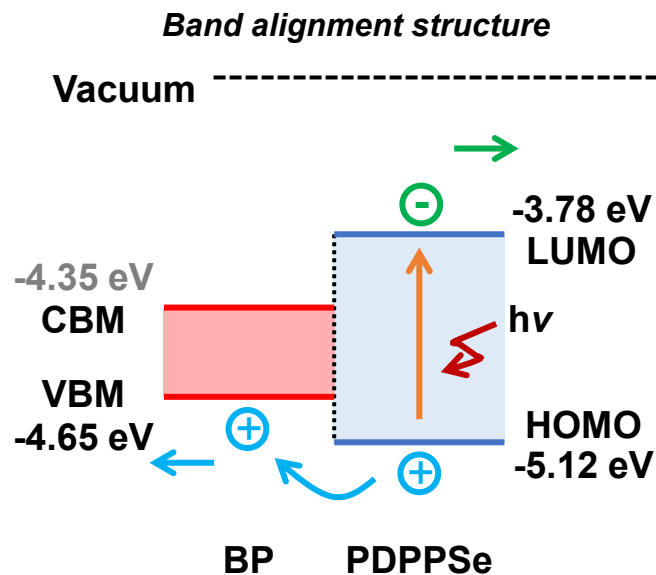
- Substantial enhancement in photoresponsivity, especially in Vis – near IR
 - No gating required (typically requires V_G of > 15 V in literature)
 - Low operation voltage (V_{DS}) of 50 mV
 - Responsivities up to 4×10^3 A W⁻¹ without external gating



BP – Organic Hybrid



- Type-I band alignment
 - Allows photogenerated carriers in polymer to flow into high mobility BP
- Organic polymer also serves as passivation layer
 - Remains stable > 28 days in ambient (BP typically degrades within 7 days)



BP – Organic Hybrid (Comparison)

Material	Substrate	Spectral Range (nm)	R (A/W)	λ_{LED} (nm)	PLED (mW/cm ²)	Testing Condition	V _{DS} (V)	V _G (V)	Ref
13 nm BP + PDPPSe	SiO ₂ /Si	280 – 1050	72.2 4.22×10^3	1050 280	3	Ambient	0.05	0	This work
7 nm BP + WSe ₂	SiO ₂ /Si	400 – 1550	1×10^3	637	1	Ambient	0.5	0	12
16 nm BP + InSe	SiO ₂ /Si	405 – 1550	53.7	655	50	Ambient	1.0	-20	11
8 nm BP	SiO ₂ /Si	400 – 940	0.0048	640	16	Vacuum	0.2	0	10
120 nm BP	SiO ₂ /Si	532 – 1550	0.0005 0.002	1550 532	3.1×10^6	-	0	0	27
28 nm BP	SiO ₂ /Si	1550	1.55	1550	9270	Ambient (h-BN)	0.5	0	28
4.5 nm BP	SiO ₂ /Si	310 – 950	1.82 9×10^4	950 310	2 - 31	Vacuum	0.1	-80	4
8 nm BP	SiO ₂ /Si	400 – 900	1×10^3 5.6×10^4	900 633	0.5	Vacuum	-1.0	-15	9
7 nm BP	SiO ₂ /Si	532 – 940	0.003 0.028	940 532	$0.26 - 3.03 \times 10^{-3}$	Vacuum	0	7 – 12	29
30 nm BP	SiO ₂ /Si	570 – 1700	5	570	1	Ambient (Al ₂ O ₃)	0.05	-20	30
10 nm BP	PI/PET	830	53	830	16.5	Ambient (Al ₂ O ₃)	0.3	-4	31

Summary

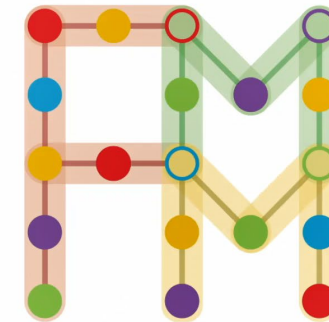


- Multilayer BP – organic hybrid broadband photodetectors
 - Simple hybridization process
 - Broadband spectral detection range: 280 nm (UV) to 1050 nm (near-IR)
 - High responsivities → up to $4 \times 10^3 \text{ A W}^{-1}$
 - No external gating needed ($V_G = 0$)
 - Low operating voltages ($V_{DS} = 50 \text{ mV}$)
 - Stable in ambient conditions > 28 days
- Applications
 - Colour imaging
 - Optical communications

Connect With Us!



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FUNCTIONAL MATERIALS
AND MICROSYSTEMS